

## New stable beam developments

F.Lemagnen and GCS team





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### Summary:

*I- Facility and equipments for the tests* 

**II- Silicon beam production** 

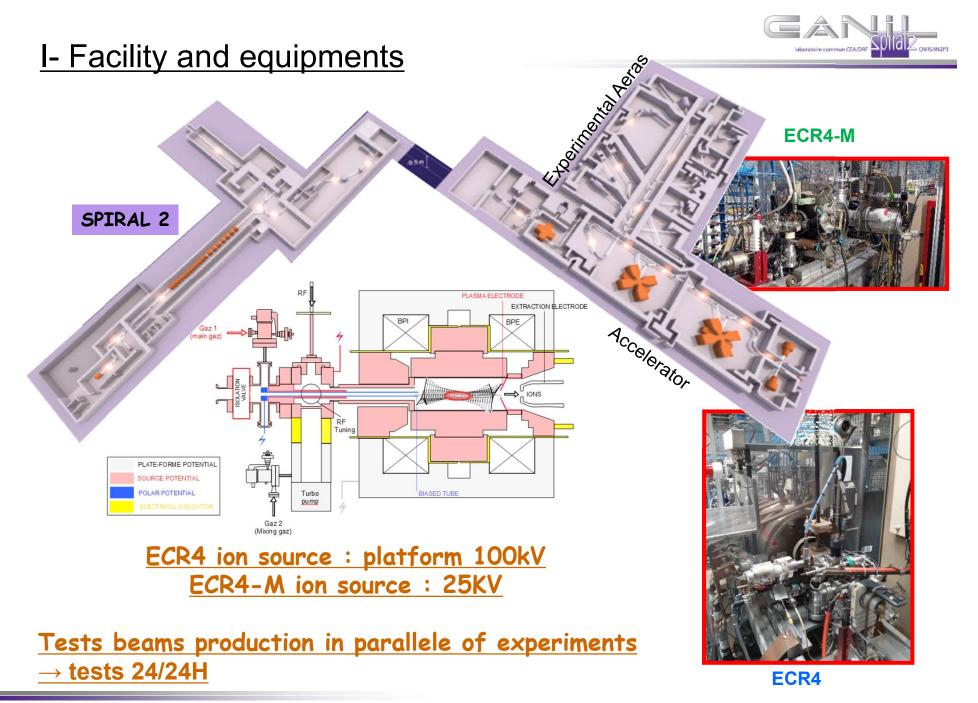
III - Tungsten beam production

**IV: Tellurium beam production** 

V: Thorium beam production

VI: The First beams tests with HT oven

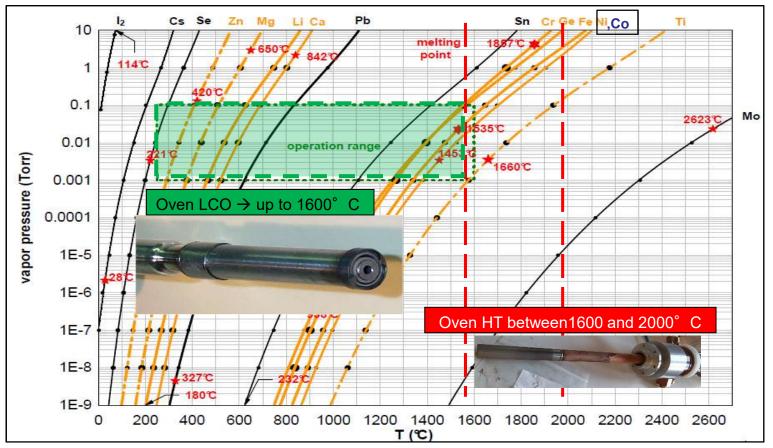
**VII: Conclusion** 



GCM 2022- F.LEMAGNEN

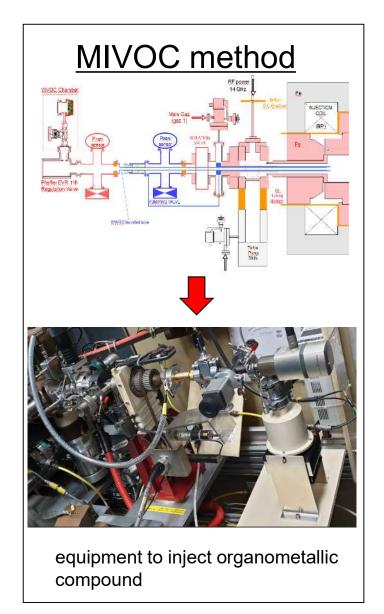


# Oven method



- > A lot of isotopically enriched elements are evaporated by oven (oxyde and metallic form)
- Control of evaporation
- High charges states can be optimized





#### **Metallic beams with MIVOC:**

Ni, Fe, Mg, Cr, Ti

For natural elements : Several Commercial compounds can be found.

R&D to obtain synthesis with the isotopically enriched element. => B.GALL's team IPHC- Strasbourg

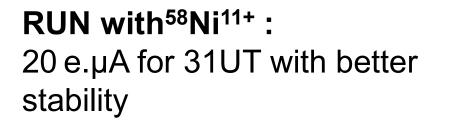
Several syntheses could be developped to replace the evaporation of element with high vapor pressure (difficulties of evaporation control with oven)

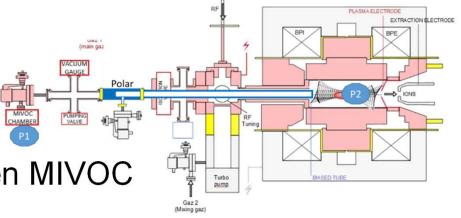
In progress: synthesis of Uranocene First test in March 2022 without success Second test in 2023

#### Upgrade of MIVOC system (2021-2022)

Goal:

- $\Rightarrow$  Optimization of regulation
- ⇒ Increase conductance between MIVOC chamber and plasma chamber
- $\Rightarrow$  Design to stop the insulator metalization

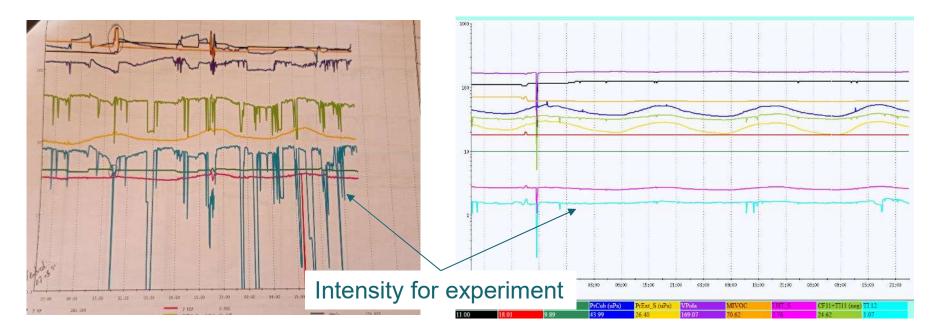








Results for 4 days before and after upgrade with <sup>58</sup>Ni<sup>11+</sup>



2021

2022

- $\Rightarrow$  Intensity a little bit higher (20e.µA compare to 15e.µA)
- $\Rightarrow$  More stable beam
- $\Rightarrow$  Reduce tuning interventions along the experiment

#### **II-** Silicon beam production



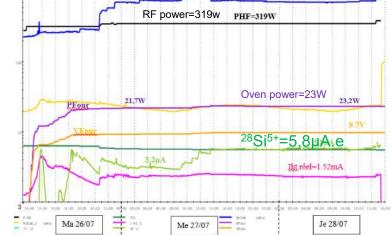
**Disjonction BPE** 

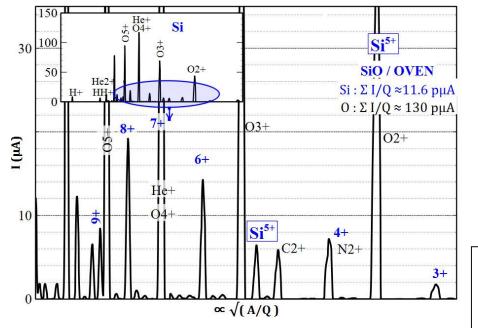
7,4.10-6mbars











<u>Compound:</u> SiO natural <u>Vapor pressure :</u> 10<sup>-2</sup> mbars for 1080° C <u>Interest of using:</u>Several isotopicaly enriched samples with this compound (<sup>30</sup>SiO, <sup>29</sup>SiO)

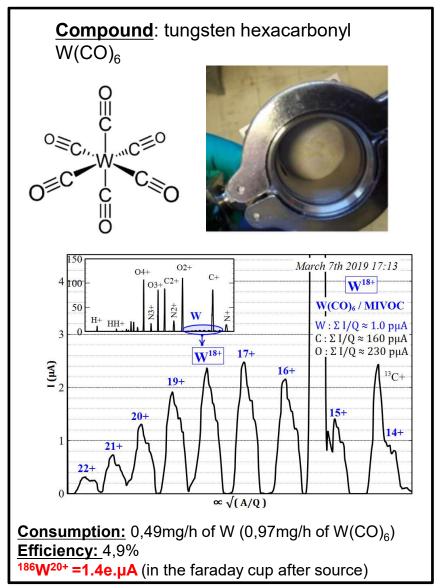
Consumption: 0,59mg/h of Si (0,89mg/h of SiO) Efficiency: 6%

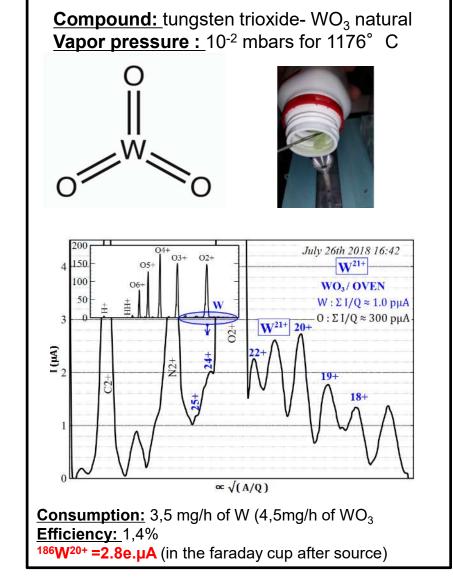
#### Example of beams available for physics

 $^{28}\text{Si}\,^{7/14+}$  at 95 MeV/A $\rightarrow$  0,4 p.µA on the target  $^{30}\text{Si}\,^{7/14+}$  at 85 MeV/A $\rightarrow$  0,4 p.µA on the target



#### III-Tungsten beam production



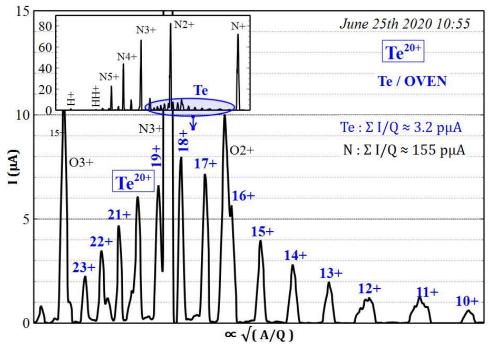


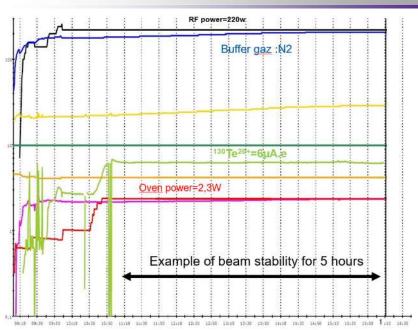
<sup>186</sup>W<sup>24+</sup> at 6 MeV/A $\rightarrow$  11p.nA on the target

#### **IV-Tellurium beam production**









Compound: <sup>130</sup>Te (99,8% enriched sample) Vapor pressure : 10<sup>-2</sup> mbar for 360° C Melting point: 452° C

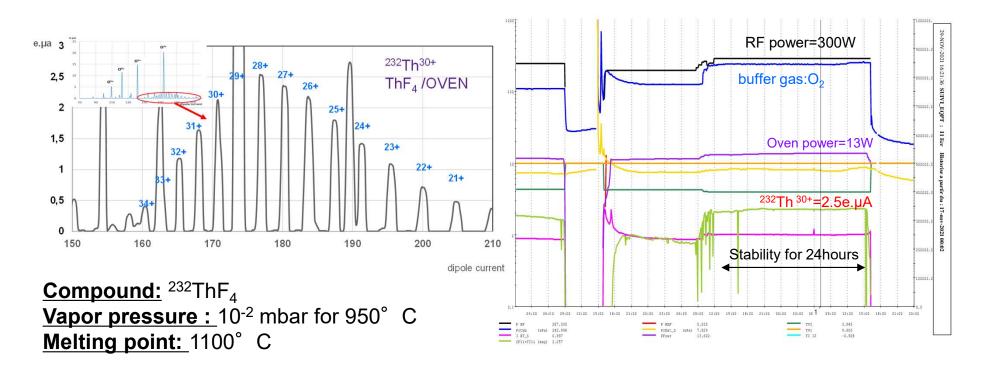
Consumption: 0,52mg/h of <sup>130</sup>Te <u>Efficiency:</u> 7,5% <sup>130</sup>Te<sup>20+</sup>=6e.μA (on the faraday cup after ion

source)

<sup>130</sup>Te <sup>19+</sup> at 8 MeV/A $\rightarrow$  50p.nA on the target

#### V-Thorium beam production





Consumption: 0,1mg/h of <sup>232</sup>Th Efficiency: 8%

> VAMOS experiment proposal:  $^{232}$ Th  $^{30+}$  at 6,1MeV/A $\rightarrow$  12p.nA on the target

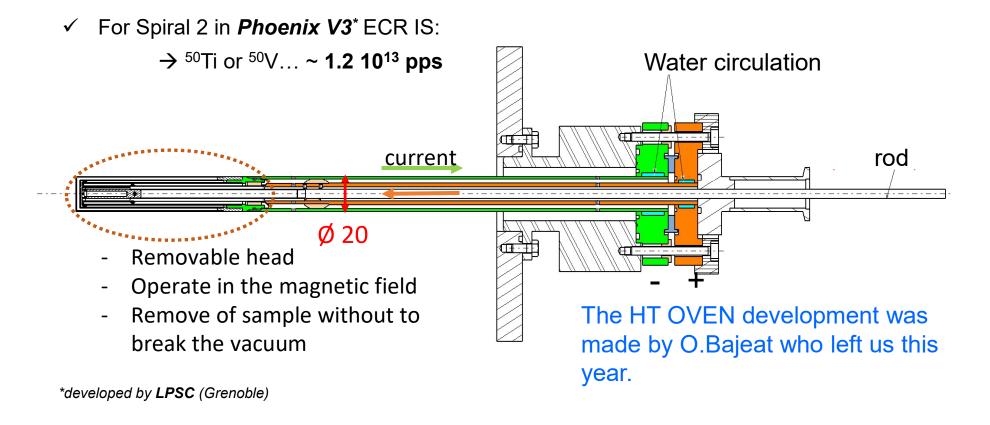
> An other example of intensity  $^{232}$ Th  $^{34+}$  at 8MeV/A $\rightarrow$  2p.nA on the target



### The goal of HT oven development

✓ For Ganil-Cyclotrons in ECR4 source:

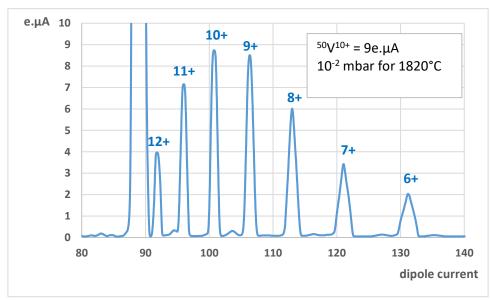
 $\rightarrow$  increasing metallic beams intensities which are produced today by sputtering method (<sup>238</sup>U, <sup>181</sup>Ta, ....)

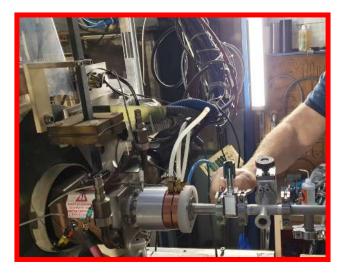


#### Test of vanadium in ECR4-M ion source





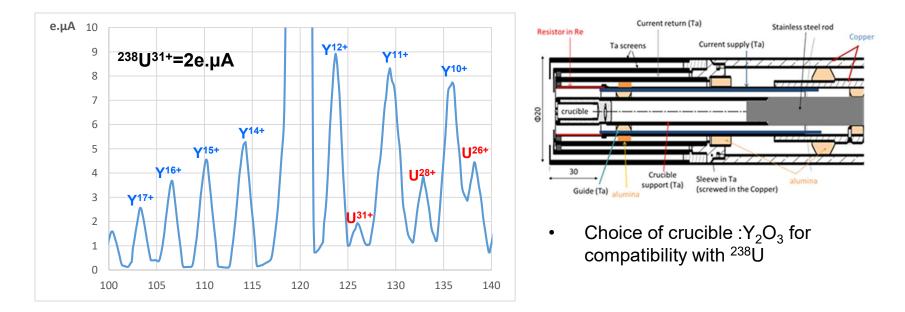




- $\succ$  4 days of continue running with V and 25 days total operation in 2021
- > Oven validated to evaporate Uranium



#### Test of uranium in ECR4-M ion source

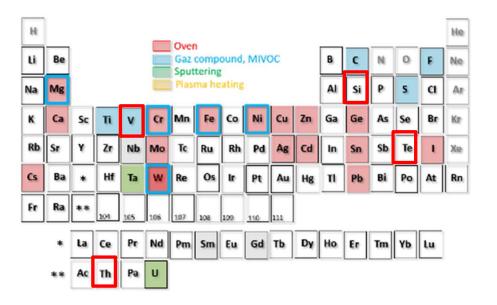


- Yttrium pollution due to evaporation of crucible
- Intensity of Uranium interesting despite the pollution and the lower of ion source 's perform (modification of RF injection with HT oven)
- $\succ$  Next test with UO<sub>2</sub>

#### V-Conclusion



- Four new ions beams availables (Si, W, Te, Th)
- > Carbonyl compounds: New way to produce other metallic elements.
- News organometallic syntheses could be developped depending of physics request.
- ➢ HT oven up to 2000° C is a successful and useable for operation



Thank you for you attention!